



*ITW*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: **ROBIN LYNN  
ALMES ET AL.**

Serial No.: 10/823,981

Filed: 14 APRIL 2004

For: **SYSTEM AND METHOD FOR  
CHARGE-BALANCED,  
CONTINUOUS-WRITE MASK AND  
WAFER PROCESS FOR IMPROVED  
COLINEARITY**

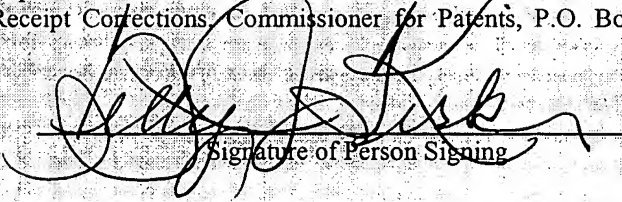
§ Attorney Docket No. **HSJ920040029US1**  
§  
§  
§ Examiner: **UNKNOWN**  
§  
§  
§ Art Unit: **2812**  
§  
§  
§

**REQUEST FOR CORRECTED FILING RECEIPT**

O.I.P.E. – Filing Receipt Corrections  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicants hereby request that a Corrected Filing Receipt be issued for the above-identified patent application. Please amend the Filing Receipt as follows:

<b>CERTIFICATE OF MAILING</b> 37 CFR 1.8	
I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to O.I.P.E. – Filing Receipt Corrections, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on August 10, 2004.	
Betty J. Kirk _____ Type Name of Person Signing	 _____ Signature of Person Signing

It is hereby requested that a correction be made under the caption "**Attorney Docket No.**" on the face of the Filing Receipt. The Attorney Docket No. is incorrectly cited as "HSJP920030029US1" when in fact, the Attorney Docket No. is:-- **HSJ920040029US1**-- . Please correct the Filing Receipt to reflect the correct Attorney Docket No., which is:

**--HSJ920040029US1--.**

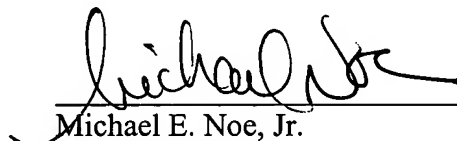
Further, it is hereby requested that a correction be made under the caption "Applicant(s)" on the face of the Filing Receipt. The third Applicant is incorrectly listed as: "Mary Kathryn Gutberlet" when in fact, her name is -- **Mary Kathryn Gutberlet** --. Please correct the Filing Receipt to reflect the third Applicant's correct name, which is:

**-- Mary Kathryn Gutberlet --.**

A photocopy of the Filing Receipt with the requested changes noted thereon is enclosed for reference.

No fee is believed to be required at this time; however, in the event any fees are required, please charge **Hitachi Global Storage Technologies' Deposit Account No. 50-2587**.

Respectfully submitted,

  
\_\_\_\_\_  
Michael E. Noe, Jr.  
Registration No.: 44,975  
BRACEWELL & PATTERSON, L.L.P.  
P.O. Box 61389  
Houston, Texas 77208-1389  
512-472-7800

ATTORNEY FOR APPLICANT(S)

HSJ920040029US1



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE  
United States Patent and Trademark Office  
Address: COMMISSIONER FOR PATENTS  
P.O. Box 1450  
Alexandria, Virginia 22313-1450  
www.uspto.gov

APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/823,981	04/14/2004	2812	990	HSJ920030029US1	4	25	2

BRACEWELL & PATTERSON, L.L.P.  
P.O. BOX 61389  
HOUSTON, TX 77208-1389



HSJ920030029US1  
HSTJ920040029US1

CONFIRMATION NO. 5316

UPDATED FILING RECEIPT



\*OC000000013355311\*

Date Mailed: 07/27/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Robin Lynn Almes, Sunnyvale, CA; ✓  
Mark Anthony Church, Los Gatos, CA; ✓  
Mary Kathryn Gutberlet, Prunedale, CA; ✓  
Jiunn Tsay, San Jose, CA; ✓  
Benjamin Lu Chen Wang, San Jose, CA; ✓

Kathryn

Assignment For Published Patent Application

Hitachi Global Storage Technologies Netherlands B.V.;

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted: 06/23/2004

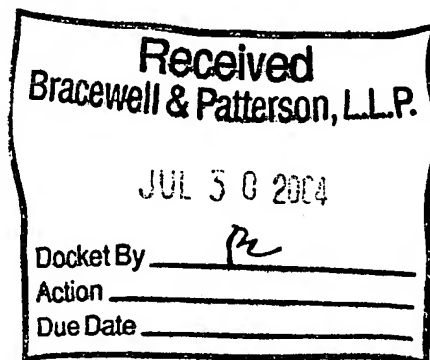
Projected Publication Date: 10/20/2005

Non-Publication Request: No

Early Publication Request: No

Title

System and method for charge-balanced, continuous-write mask and wafer process for improved



**Preliminary Class**

438

---

**LICENSE FOR FOREIGN FILING UNDER  
Title 35, United States Code, Section 184  
Title 37, Code of Federal Regulations, 5.11 & 5.15**

**GRANTED**

The applicant has been granted a license under 35 U.S.C. 184, if the phrase "IF REQUIRED, FOREIGN FILING LICENSE GRANTED" followed by a date appears on this form. Such licenses are issued in all applications where the conditions for issuance of a license have been met, regardless of whether or not a license may be required as set forth in 37 CFR 5.15. The scope and limitations of this license are set forth in 37 CFR 5.15(a) unless an earlier license has been issued under 37 CFR 5.15(b). The license is subject to revocation upon written notification. The date indicated is the effective date of the license, unless an earlier license of similar scope has been granted under 37 CFR 5.13 or 5.14.

This license is to be retained by the licensee and may be used at any time on or after the effective date thereof unless it is revoked. This license is automatically transferred to any related applications(s) filed under 37 CFR 1.53(d). This license is not retroactive.

The grant of a license does not in any way lessen the responsibility of a licensee for the security of the subject matter as imposed by any Government contract or the provisions of existing laws relating to espionage and the national security or the export of technical data. Licensees should apprise themselves of current regulations especially with respect to certain countries, of other agencies, particularly the Office of Defense Trade Controls, Department of State (with respect to Arms, Munitions and Implements of War (22 CFR 121-128)); the Office of Export Administration, Department of Commerce (15 CFR 370.10 (j)); the Office of Foreign Assets Control, Department of Treasury (31 CFR Parts 500+) and the Department of Energy.

**NOT GRANTED**

No license under 35 U.S.C. 184 has been granted at this time, if the phrase "IF REQUIRED, FOREIGN FILING LICENSE GRANTED" DOES NOT appear on this form. Applicant may still petition for a license under 37 CFR 5.12, if a license is desired before the expiration of 6 months from the filing date of the application. If 6 months has lapsed from the filing date of this application and the licensee has not received any indication of a secrecy order under 35 U.S.C. 181, the licensee may foreign file the application pursuant to 37 CFR 5.15(b).